

# A foldable high transparent fluorinated polyimide (HFBAPP/6FDA) film material for transparent flexible substrate

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## Abstract

Flexible transparent substrate materials, which was able to withstand high dynamic strain, in contrast to traditional substrate materials. A flexible and transparent material with advantages including transparency, stable size, and excellent corrosion and electrical resistance was provided. The polyimide(PI) film was prepared by introducing a structure with a high content of F atom and a fine optimization process to enhance the various properties of the film. However, the properties of the films were optimized effectively by gradient vacuum and secondary dissolution so that the film had a transmittance at 400 nm of 82%. The films with low dielectric constant and low dielectric loss represent the breakdown strength of 202 kV/mm. The glass transition temperature of the film was 267 °C, and the thermal expansion coefficient was 35ppm/k (30 °C~270 °C), indicated outstanding thermal dimensional stability. Therefore, this polyimide film was an optoelectronic device with extremely high application potential on the folding mobile phone and the PI film is the finest materials of screen.

Keywords: transparent PI, transmittance, insulation, thermal performance, dielectric properties.

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## 1. Introduction

Transparent flexible substrate materials were capable of bending deformation, compared with traditional glass substrate materials. In recent years, the demand and technical requirements of the transparent flexible substrate in the flexible display screen and other fields were increasing<sup>[1-4]</sup>. A new replacement of glass substrate material was provided by PI film, which was good at transparency, mechanical strength, corrosion resistance, heat resistance.

With the creasing of technology, enterprises were not satisfied with the status quo that grow a large-scale market for transparent flexible materials<sup>[5,6]</sup>. Hitherto, the key issue of the high transparent polyimide included high optical transmittance(TR)<sup>[7-9]</sup> and low yellow value<sup>[10,11]</sup>. It was well known that polyimide was generally shown to be brown yellow and caused TR to be lower. A high yellow value led to the bad vision and the film unable to be used on a large scale. Stretchability, electrical and thermal stability under mechanical deformation were new essential criteria because transparent films need to be applicable to next-generation material. Thus far, thin transparent polyimide film had served as an ideal choice for because of good resistance to shock-resistant to many chemicals and good heat resistance<sup>[12-15]</sup>.

In the past few decades, new PI had been grown by excellent performance as film material, such as aliphatic  $PI^{[16,17]}$ , aromatic  $PI^{[18,19]}$ , and other  $PI^{[20,21]}$ .Imposing the conjugate plane structure or polar structure on the PI film was an essential method in principle. The aliphatic PI was a better compared with aromatic PI that was attributed to the molecular weight.

Transparent properties were considered the fatal flaw that limited the PI film qualities' s application in the flexible screen application field. The traditional aromatic benzene type PI was usually brownish yellow and low light transmittance, which was mainly due to the strong charge-transfer complex(CTC)<sup>[22]</sup> formed between aromatic dianhydride and aromatic diamine and some dark functional groups were produced during thermoimination. Therefore, the surface of PI film had a certain orientation structure by introducing F group<sup>[23-26]</sup>, alicyclic polyimides<sup>[27-29]</sup>and so on into the PI system. Studies had shown that the introduction of orientation structure could effectively eliminate the CTC effect within the molecule, and the introduction of macrogroup side groups could effectively eliminate the CTC effect between molecules. <sup>[30,31]</sup> The solvent contains amides, which were prone to oxidation in the heating process to make the film darker. A gradient vacuum method was developed, which could effectively remove the influence of solvent without affecting the flowability of PAA glue soluting and the performance of PI film.

In this paper, a transparent material was provided by PI-HFBAPP/6FDA film. This transparent film would not be corroded and deformed by chemical agents and had good transparency. The orientation of the folding screen would not affect the visual experience of the reader. By adjusting the polymer structure and optimizing the process especially, the film with high visible light transmittance was prepared on the premise of ensuring the film performance. Thus, this film had great development space in the market potential in the future.

## **2 Experimental Section**

#### 2.1 Experiment materials

Dimethylacetamide(DMAC) was purchased from Tianjin Fuyu Fine Chemical Co., Ltd. 4,4'-(Hexafluoroisopropylidene) diphthalic anhydride(6FDA) was purchased from Wuhan lullaby pharmaceutical chemical Co., Ltd, the purify was 99%. 2,2-Bis[4-(4-aminophenoxy)phenyl]-hexafluoropropanane(HFBAPP) was purchased from Shanghai Macklin Biochemical Co., Ltd, the purify was 99%. 4,4-oxydianiline(ODA) was purchased from Sinopharm Group Chemical Reagent Co., Ltd. 3,3',4,4'-biphenyl tetracarboxylic dianhydride(PMDA) was purchased from Shanghai Macklin Biochemical Co., Ltd. All the chemicals were analytical grade reagents that were commercially available and were used without further purification.

#### 1.2 Experimental Procedure

The reaction equation of HFBAPP as diamine monomer, 6FDA as dianhydride monomer was taken as an example. The reaction equation of the polymerization was shown in Figure 1.

Polyimide films were synthesized using the dianhydride 6FDA or PMDA, the diamines HFBAPP or ODA in the polar aprotic DMAc, as shown in Figure 1. The film preparation of PI-HFBAPP/6FDA was taken as a representative to illustrate the detailed procedures. The reaction flow chart of PI-HFBAPP/6FDA Film was shown in Figure 2.

By using ice-water mixing bath and nitrogen protect reaction process, HFBAPP(1.985 g, 0.03828mol) was added to DMAC(15 ml) solvent and stirred slowly until completely dissolved. 6FDA(1.701 g, 0.003829mol) was added into the reaction system six times. The time interval for each addition of monomers was 15 minutes and added a monomer in an amount half as small as it was left. Stirring continued for 2 hours after the average viscous molecular weight climbed.

The polymer was transfer into a small beaker and the beaker was placed in a vacuum box. Then the air was extracted from the vacuum box so that the gel did not contain bubbles.



Figure 1. Preparation of PI-HFBAPP/6FDA Film.





After cleaning the glass plate, the standing polyamic acid(PAA) was poured onto the glass plate and spread with a scraper of a certain thickness. The size of the glue film was 20 cm  $\times$  25 cm and the final formed thickness of the film was 10  $\mu m \sim 50 \ \mu m.$ 

The film was put into the oven, and the removal of solvents from the film was carried out by a gradient vacuum. As a consequence, the treated film would avoid oxidation. The specific process was shown in Table 1.

The film was put into the oven and the thermal imidization of the film was carried out by gradient heating. The specific process was shown in Table 2.

## 3. Measurement

The transmittance of the film and the different PI film proportions were analyzed by the UV-visible spectrophotometer of Shimadzu UV-2450. Test conditions: the wavelength was 600-250 nm and the sample size was 20-30 mm. The Bruker-EQUINOX 55-type Fourier transform infrared spectrometer manufactured by Germany was used to attenuate the total reflection infrared attachment. The polyimide film was characterized. The test condition was that the resolution was 4 cm<sup>-1</sup>, the scanning time was 16 times of the sample to be tested, the background was scanned 16 times, the delay time was 10s, and the test range was 500-4000 cm<sup>-1</sup>.

The dimensional stability of the films wares using by L75 Pt vs/VD vertical mode thermal dilatometer. Heating interval 0~270 °C, heating rate 5 °C/min. The glass transition temperature and storage modulus of the PI films were measured by the dynamic mechanical analysis(DMA). All test samples were rectangular, with a length of 20 mm and a width of 8 mm.

The dielectric constant and dielectric loss of the PI film was tested by an Alpha-a-type broadband dielectric spectrometer manufactured by Novocontrol Company of Germany.

The breakdown strength of the PI film was measured by using the HT-5/20 breakdown voltage tester developed by the Guilin Electrical Equipment Scientific Research Institute.



Figure 2. Reaction flow chart of PI-HFBAPP/6FDA Film.

#### Table 1. Gradient vacuum process.

Stage	А	В	С	D	E	F	G	Н	Ι
Time/min	10	20	10	10	20	20	20	20	30
Vaccum/1atm	0.4	0	0.5	0.6	0	0	0.7	0.7	0
Temperature/°C	80	80	80	80	80	100	100	120	120

#### Table 2. Thermoimidization gradient heating schedule.

Temperature/°C	Climb to 80	80	80 to 120	120	120 to 160	160	160 to 200	200	200 to 250	250	250 to 300	300
Time/min	15	45	10	20	10	20	10	20	10	20	10	20

# 4. Result of discussion

### 4.1 FTIR characterization

The chemical structures of the pure PI film and PI-vacuum treatment/secondary film formation were confirmed by FTIR spectroscopy, and it was shown in Figure 3.

As a consequence, there were 6 characteristic absorption peaks of polyimide films at 1787 cm<sup>-1</sup>, 1729 cm<sup>-1</sup>, 1600 cm<sup>-1</sup>,



Figure 3. Infrared spectrum of pure PI film and PI film after Process Optimization.

1500 cm<sup>-1</sup>, 1380 cm<sup>-1</sup>, 850 cm<sup>-1</sup>, where 1787 cm<sup>-1</sup> corresponded to the asymmetric expansion vibration of C=O, and the 1729 cm<sup>-1</sup> corresponded to the C=O symmetric expansion vibration. Compared with ordinary PI, the carbonyl stretching vibrations on the fluorinated PI rings moved toward higher wavenumbers. It was due to the inducing effect of the trifluoromethyl group that made the carbonyl double bond enhance and the frequency of stretching vibration increase. The peaks at 1600 cm<sup>-1</sup> corresponded to N-H flexural expansion vibration. The peaks at 1500 cm<sup>-1</sup> and 850cm<sup>-1</sup> corresponded to the vibration of the benzene ring skeleton. The absorption peak at 1380 cm<sup>-1</sup> represented the symmetric contraction vibration of the C-N, and the 725 cm<sup>-1</sup> corresponded to the bending vibration of the C=O. These characteristic peaks were consistent with the standard peak positions of the PI in Figure 3, indicating the presence of PI structure and characterizing the PI structure. From Figure 3 that the change of process does not change the structure of the polymer, which could be proved by the fact that there was no difference between line 4 (PI-HFBAPP/6FDA) and line 5 (PI-HFBAPP/ 6FDA-remade).

#### 4.2 Characterization and optoelectronic properties

The optical performance of CPI films was shown in Figure 3. Because of the flatness of coating and PAA glue soluting could be naturally leveled. The CPI films were uniformly distributed on the glass substrate and separated breezily. Four kinds of films to meet different production requirements were prepared, and the transmittances were characterized. As shown in Figure 4a, several kinds of CPI



Figure 4. Transparent of PI composite films with different preparation process. (a) Transmittance of different monomers PI (b) Different thickness transmittance of PI-HFBAPP/6FDA (c) Effect of technology on the transmittance of PI (d) Optimization of thin film transmittance.

films exhibit a high transmittance. The 341 nm was UV cutoff wavelength of pure PI-HFBAPP/6FDA, it was the least of PI films prepared from different monomers and the transmittance was also the best. As shown in Figure 4b, the lower the thickness, the better the transparency of the films. The reason was that the thicker films were easy to clip impurities or tiny bubbles in the process, and there were not conducive to solvent volatilization. The higher the yellow value of the film thickness also reduces the transparency of PI to a certain extent. The transparency of pure PI films at 400 nm was 67% (CPI-3 15 µm), 37% (CPI-4 30 µm), 3%(50 µm), and 500 nm was 94%(15 µm), 93%(30 µm) and 87%(50 µm).

The technology of gradient vacuum could improve the light transmittance, because it could avoid the discoloration caused by the solvent oxidation during the thermal imidization process and could deal with the bubble problem during the synthesis process, it was shown in Figure 4c that the technology of gradient vacuum could improve the light transmittance by about 2%. After the secondary film-forming process after dissolution(CPI-2 30 µm) was prepared, the free monomer and colored impurity in the polymer could be effectively removed. It would improve the wavelength of the UV stage and reduce the transmittance of 420 nm band, which was due to the introduction of a new solvent(NMP) to produce a certain residue in the process of heating secondary film formation. It was shown in Figure 4d that if reducing the thickness of the film, it would greatly reduce the residual solvent NMP. In the film, the transmittance(CPI-1 15 µm) could reach 82% at 400 nm and the yellowness index is 5.5.

Yellowness index (YI) is used to characterize the yellowing degree of colorless, transparent, translucent or near white polymer materials, which is one of the important optical indexes in resin plastics industry.

$$\mathrm{YI} = \frac{100 \big(\mathrm{CxX} - \mathrm{CzZ}\big)}{\mathrm{Y}}$$

The YI of the PI-(CPI-1 15  $\mu$ m) is 5.5 and the PI-HFBAPP/ PMDA is 78.6. The YI of the film is greatly decreased a lot by structural design and process optimization. As you can see from Figure 5, the yellow effect of the film is not visible at all.

As could be seen from Figure 6, the transparency of the same series of PI films increased with the increase of the F group ratio. We attribute the reason for the introduction of the side group in the PI chain that destroyed the charge transfer complex(CTC). Increasing the high electronegative group was an effective way to reduce the CTC effect by weakening the intermolecular and intramolecular interactions, reducing the number of free monomers, and introducing large resistance side groups.

## 4.3 Thermal performance characterization

Dynamic thermo-mechanical analysis(DMA) was used to measure the modulus of the material along with the change of temperature, the glass transition temperature of the material in the characterization of molecular chain motion, and molecular inter-atomic forces. The change of loss modulus(E") represented the intensity of the movement of molecular chains. The change of storage modulus(E') represented the strength of intermolecular forces.

From the curves of loss modulus(E'') versus temperature in Figure 7, it could be seen that the peak temperature of the respective loss modulus represented the glass transition temperature, the Tg of PI-HFBAPP/6FDA was 267 °C, and energy storage density up to 1170 MPa. The larger the molecular weight of the material, the more tangles between the molecules. The more heat generated by friction, the greater the storage modulus. After the tangent of the curve, the temperature continued to increase, the value of the storage modulus momentarily dropped to zero, and the modulus decayed completely in the temperature range where the temperature increase was small.



Figure 5. The actual effect of PI film.



Figure 6. Schematic diagram of the charge transfer of CTC.



Figure 7. Glass transition temperature and storage modulus of PI composite films.

Thermo-mechanical analysis(TMA) characterized in the case of a certain temperature program, the load force was close to zero. The dimensional variation of the measured sample was functional with temperature or time in isotropic polymers, the molecular chains were promiscuously oriented, and their thermal expansion coefficient strongly depended on the weak intermolecular interactions.

In Figure 8, the thermal expansion coefficient of the films prepared by different processes was different, and the film without doping the filler achieved a more ideal effect. The thermal expansion coefficient of PI-HFBAPP/6FDA

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cure film was 67 ppm/k. The presence of CF3 resulted in a decrease in the packing density of PI macromolecules, an increase in the free volume of the molecular chain, and a smaller interaction between the molecular chains. Therefore, by adding less F element would decrease the coefficient of linear thermal expansion. However, the structure with a high content of F atom was more stable and could be used to prepare films with higher molecular weight. It increased the packing density of molecules and reduces the free space in the same volume. Under the same conditions, the dimensional stability of the film was better. After the process optimization, the thermal expansion coefficient of the PI film increased. The reason was that the molecular weight of the film was lost after the secondary dissolution process, the intermolecular force was reduced, and the heat required to expand the distance between molecules was reduced. For this problem, we could only optimize the process as far as possible to reduce the loss caused by repeated coating. Theoretically, if the process was optimized enough, the thermal expansion coefficient of the second film was expected to be lower than that of the pure film.

#### 4.4 Characterization of electrical properties

The dielectric property of the PI films was characterized from 100 Hz to 107 Hz and obtained the dielectric constant. Since the dielectric loss was related to the energy dissipation due to the oscillating electric field, it was necessary to select the low dielectric constant and low dielectric loss materials. Since the dielectric loss was related to the energy dissipation due to the oscillating electric field, it was necessary to



Figure 8. Thermal expansion coefficient diagram of PI film.



Figure 9. Dielectric properties of PI different films.

select the low dielectric constant and low-dielectric loss materials and longer service life. Accounting to Figure 9, PI-HFBAPP/6FDA had a lower dielectric constant that defeat traditional PI films.

The low-k and the low dielectric were attributed to increasing the spatial group of molecules by adding a C-F bond. The C-F bond had less dipole polarization. Consequently, the increase of C-F bond could effectively reduce the dielectric constant and dielectric loss. The PI-HFBAPP/6FDA film with a large number of CF3 groups had an excellent dielectric ability. The dielectric constant of the PI films was 2.1 and the dielectric loss had been below 10-2 at the full frequency band.

The breakdown field strength of the dielectric was the ultimate ability of the dielectric to maintain insulation performance under the action of an electric field. Figure 10 showed the volume resistivity and electrical field strength of PI.

Figure 10 reported the electric field and volume resistivity of the different PI. The prepared F-containing PI film reached 171.3 kV/ mm and the volume resistivity of the four films was characterized. The volume resistivity





of PI-HFBAPP/6FDA film was reached  $3.3 \times 1015 \,\Omega/m$ . In general, the dielectric breakdown occurred mainly in the weakest part of the dielectric properties of materials, and the regular structure results in fewer leakage pathways. For pure films, some of the films with the structure with a high content of F atom would distort the structure to some extent and form weak points, so the breakdown strength would be weaker than that of PI films with benzene structure to some extent. The PI(HFBAPP/6FDA) film with the structure with a high content of F atom also had a regular structure and the anti-wear loss rate was low, and the charge transfer effect inside the film was very weak. The voltage needs to consume more energy and converted it into heat energy to lose the structure of the film before it could break down at the weak point. The volume resistivity of PI film was mainly related to the intramolecular or intermolecular phase resistance. With the decrease of the internal charge of the polymer, the volume resistivity of the PI film increased, and the insulation performance of the PI film was better. The volume resistivity of the PI composite film showed the same trend as the breakdown field strength. In addition, due to the long distance between the two adjacent particles, the



Figure 10. Volume resistivity and Electrical Field strength of PI by different monomers.



Figure 11. Electric Field of PI films with different process.

barrier which hindered the carrier migration decreases, and the volume resistivity increased.

Figure 11 reported the field strength of the PI obtained by the gradient vacuum treatment and the secondary film formation could reach 202 kV/ mm. The reason was that the film defects and the impurities could be effectively reduced during the process treatment process. Gradient vacuum technology could effectively reduce the physical defects in the preparation process of PI films, which made PI films have a smoother surface and a higher degree of the electric field. After dissolution, the residual monomer impurities and other influencing factors could be removed by secondary film formation, and the capacity of the film properties could be further improved. Compared with the film after the gradient vacuum, the PI film after dissolution increased more insulation performance.

## 5. Conclusion

Two series of PI were synthesized by the two-step method from HFBAPP, 6FDA, ODA, and PMDA. Various optimization attempts were made to determine the effect of gradient vacuum and secondary dissolution on the research direction. With the increase of F content in the film, the effect of CTC was greatly weakened, the transmittance was obviously improved, the dielectric constant and dielectric loss were reduced, and the coefficient of thermal expansion was reduced. The process-optimized PI-HFBAPP/6FDA film reached 82% at 400 nm and total penetration at 425 nm. The glass transition temperature was 267 °C and the storage modulus was 1170 MPa. The coefficient of thermal expansion was 67 ppm/k. The film had excellent electrochemical performance, which breakdowns resistance voltage was 5.3 kV and the breakdown field strength was 202 kV/mm. The dielectric constant was 2.1, the dielectric loss was less than  $10^{-2}$  and bulk resistance was  $3.3 \times 10^{15} \Omega \cdot m$ . In summary, it effectively inhibits that the CTC action in the polyimide film structure and ensures the other properties of PI by optimizing the process. The PI transparent film had high permeability, excellent heat resistance, excellent dimensional stability, high breakdown field strength, low dielectric constant, and low dielectric loss. The OLED

commonly used in folding screens have the problems of low melting point and short service life - unlike the PI films. However, this PI film had considerable progress in the transparent film and a good application prospect for the flexible display market. We have achieved good performance in the transparent properties of films and it can be effectively applied to practical improvements.

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